

Search Notes

Application No.

10/635,803

Examiner

D. Rutledge

Applicant(s)

OKUBO ET AL.

Art Unit

2851

SEARCHED

Class	Subclass	Date	Examiner
355	53	9/18/2004	DR
206	710, 723	9/18/2004	DR
414	217.1	9/18/2004	DR
414	931,937	9/18/2004	DR
414	416.01	9/18/2004	DR

INTERFERENCE SEARCHED

Class	Subclass	Date	Examiner
355	53	9/18/2004	DR
206	710,723	9/18/2004	DR
414	217.1	9/18/2004	DR
414 416.01, 931, 937		9/18/2004	DR

**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
pod or (mask or reticle), hold\$3 or retain\$3 or support\$3, circular or round, base, cover or top or lid, support adj block	9/18/2004	DR
cicompliant or resilient, contact, force or pressure or press or pressing, plural\$3 or three, mounting, position or location,	9/18/2004	DR
handling or safe, area or zone or region, block or protrusion or protuberance, lithography or photolithography or	9/18/2004	DR
microlithography	9/18/2004	DR